G.R. No.

Paper lode - 127-105A (T2)

MARCH 2018 / IN - SEM (T2)

F. Y. B.TECH. (COMMON) (SEMESTER - II)

COURSE NAME : Engineering Physics (2017 PATTERN)

COURSE CODE: ES10175A

Time :[1 Hour]

[Max. Marks: 30]

- (*) Instructions to candidates:
- Answer Q.1 OR Q.2, Q.3 OR Q.4
- Figures to the right indicate full marks.
- Use of scientific calculator is allowed
- Use suitable data wherever required
- Q1 (a) Define Fermi level for a semiconductor. What is Fermi-Dirac [6] probability distribution function? Explain the terms used in it. Show that the probability of finding an electron with energy E_F+ΔE is equal to the probability of absence of an electron with energy $E_F-\Delta E$.
 - (b) Draw the energy level diagram for an unbiased p-n junction diode [6] at equilibrium. Explain the formation of built in potential on the basis of charge re-distribution in both regions. Derive the expression for built in potential (Vbi) for a p-n junction diode.
 - (c) Find E_F-E_{Fi} for an n-type semiconductor if the doping [4] concentration is $N_D = 2.1 \times 10^{15}$ /cm⁻³. Given $n_i = 2.4 \times 10^{13}$ /cm⁻³ at 300K. Boltzmann constant k = 8.6×10-5 eV/K. How far is E_F from Ec if the band gap is 0.7 eV for Ge?
- Given density of states $g_c(E) = \frac{4}{\sqrt{\pi}} \left[\frac{m_e^*}{2\pi\hbar^2} \right]^{3/2} (E E_c)^{1/2}$ for $E \ge E_c$, derive Q2 (a) an expression for electron density 'n' in the conduction band.
 - (b) Starting from the expression for current through a diode, obtain [6] expressions for current in forward and reverse bias. Explain with help of band diagram, I-V characteristics for a diode.
 - (c) Find the probability of finding an electron 0.15eV above and [4] 0.15eV below the Fermi energy at 300K, Given, k = 8.6×10-5 eV/K.
- Starting from the ideal diode equation, obtain expressions for [6] Q3 (a) short circuit current Isc and open circuit voltage Voc. Give the expression for fill factor. Explain the terms in it and its significance using the I-V characteristics.
 - (b) Explain the functions of bypass diode and blocking diode while [4] connecting solar panels in an array.

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(c) A Si solar cell typically has reverse saturation current density $J_0=1\times10^{-12}$ A/cm². Such a Si solar cell with an area of 275 cm² is illuminated by sunlight of intensity $P_{solar}=1000\text{W/m}^2$. Short circuit current $I_{sc}=I_L=4.2$ A. If the fill factor FF of the cell is 0.65, then calculate efficiency of the solar cell at 27°C.

OR

Q4 (a) Define and explain the following battery parameters: (i) battery [6] capacity (ii) depth of discharge (iii) C-rating.

(b) Explain use of anti-reflection coating and surface texturing to [4]

enhance efficiency of a solar cell.

(c) Four solar cells are connected in series in a row. Seven such [4] rows are connected in parallel to form an array. Calculate open circuit voltage $(V_{oc})_{array}$ and short circuit current $(I_{sc})_{array}$ for the array. Given, $V_{oc} = 0.6$ V and $I_{sc} = 1$ A for a single solar cell.

basis of charge re-distribution in high resides programme

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